Electrochemical Generation of Diarylcarbenium Ions and their Reactions with Aromatic Compounds.

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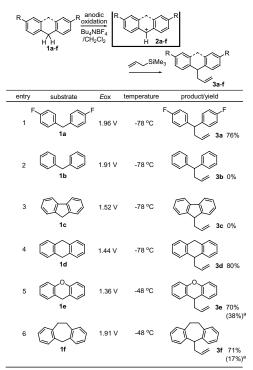
Diarylcarbenium ions have received significant research interest from a mechanistic and a synthetic view points. Some diarylcarbenium ions are rather stable and their reactivity toward nucleophiles has been extensively studied. It is also noteworthy that diarylcarbenium ions may serve as versatile intermediates for the synthesis of aryl-substituted compounds of interesting functions. Diarylcarbenium ions are often generated from the corresponding alcohols and halides by ionization in super acid. Laser-flash photolysis has also been utilized as a method for the generation of diarylcarbenium ions, although, to the best of our knowledge, the generation of diarylcarbenium ions by electrochemical methods had never been examined when we initiated this study.

We have developed the "cation pool" method that involves irreversible oxidative generation and accumulation of carbocations in the absence of nucleophiles at low temperature. *N*-Acylminium ion pools and alkoxycarbenium ion pools can be easily generated by the oxidative cleavage of C-H, C-Si, and C-C bonds. Diarylcarbenium ions are found to be generated by the "cation pool" method¹ and we applied for dendrimer synthesis.² During the course of our study, we also found that generation efficiency of diarylcarbenium ions highly depends on diarylmethanes and high reactivity of electrochemically generated diarylcarbenium ions. Here we report the detail of our findings about the "cation pool" of diarylcarbenium ions.

We initiated our study by measuring the oxidation potential of diphenylmethane derivatives. As shown in Table 1, oxidation potentials of diphenylmethane derivatives were lower than 2 V. These values indicated that all these molecules can be oxidized under conventional preparative electrochemical conditions. The low-temperature anodic oxidation of diphenylmethane derivatives was performed under the "cation pool" condition and thus-generated cations were treated with allyltrimethylsilane as a nucleophile (Table 1). When we used *p*-difluorodiphenylmethane **1a** as a precursor of the diarylcarbenium ion, the allylated product 3a was obtained in reasonable yield (76%). On the other hand, diphenylmethane 1b did not give the corresponding allylated product 3b and the significant amount (54%) of diphenylmethane 1b was recovered (entry 2). The anodic oxidation of fluorene 1c seems to be interesting because fluorenyl cation might is anti-aromatic. Though 1c was consumed completely during the electrolysis, the allylated product 3c was not obtained after treatment with allyltrimethylsilane (entry 3). 9,10-Dihydroanthracene 1d gave the allylated product 3d in 80% yield at -78 °C (entry 4). Xanthene 1e and dibenzosuberane 1f gave allylated products 3e and 3f in reasonable yields at higher temperature (-48 °C) (entries 5 and 6). In both cases, yields of allylated products were moderate at -78 °C as shown in parentheses.

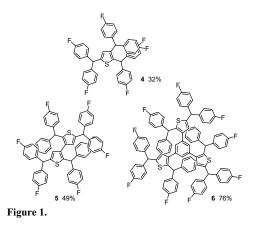
High reactivity of p-difluorodiphenylcarbenium ion **2a** inspired us to investigate multi-addition toward

Table 1.



^aReactions were performed at -78 °C.

aromatic compounds. For example, the Friedel-Crafts type reaction of diarylcarbenium ions **2a** with thiophene afforded the tri-adduct **4** in low yield (32%). Thus, we also examined 3,3'-bithiophene and 1,3,5-tri(3'-thienyl)-benzene as nucleophiles. The multi-addition of diaryl-carbenium ions **2a** toward these nucleophiles afforded tetra-adduct **5** and hexa-adduct **6** in moderate yields (49% and 76%).



References

 Okajima, M.; Soga, K.; Nokami, T.; Suga, S.; J. Yoshida, *Org. Lett.* **2006**, *8*, 5005. and references therein.
Nokami, T.; Ohata, K.; Inoue, M.; Tsuyama, H.; Shibuya, A.; Okajima, M.; Soga, K.; Suga, S.; Yoshida, *J. J. Am. Chem. Soc.* **2008**, *130*, 10864.